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Exploring the influence of the microstructure on the passive layer chemistry and breakdown for some titanium-based alloys in normal saline solution

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Abstract: The effect of microstructure and chemistry of passive films on the kinetics of passive layer growth and passivity breakdown of some Ti-based alloys, namely Ti-6Al-4V, Ti-6Al-7Nb and TC21 alloys was studied. The rate of pitting corrosion was evaluated using cyclic polarization measurements. Chronoamperometry was applied to assess the passive layer growth kinetics and breakdown. Microstructure influence on the uniform corrosion rate of these alloys was also investigated employing Tafel extrapolation and dynamic electrochemical impedance spectroscopy. Corrosion studies were performed in 0.9% NaCl solution at 37 °C, and the obtained results were compared with ultrapure Ti (99.99%). The different phases of the microstructure were characterized by X-ray diffraction and scanning electron microscopy. Chemical composition and chemistry of the corroded surfaces were studied using X-ray photoelectron analysis. For all studied alloys, the microstructure consisted of α matrix, which was strengthened by β phase. The highest and the lowest values of the β phase's volume fraction were recorded for TC21 and Ti-Al-Nb alloys, respectively. The uniform corrosion rate and pitting corrosion resistance (R_{pit}) of the studied alloys were enhanced following the sequence: Ti-6Al-7Nb < Ti-6Al-4V << TC21. The corrosion resistance of Ti-Al-Nb alloy approached that of pure Ti. The obvious changes in the microstructure of these alloys, together with XPS findings, were adopted to interpret the pronounced variation in their corrosion rates.

Keywords: Titanium-based alloys; Microstructure; Passivity breakdown; Pitting corrosion

1. Introduction

Titanium and its alloys are widely used in many industrial applications, because of their highly desirable properties, including very good mechanical properties, excellent corrosion and erosion resistance, and favorable strength to weight ratios [1]. In fact, titanium and its alloys have experienced increased use in the past years as biomaterials, because of their superior biocompatibility, high resistance to localized and generalized corrosion, and their good mechanical properties (fatigue resistance) [2]. Among all titanium and its alloys, the commonly used materials in biomedical area are commercially pure titanium (cp Ti) and its (α + β) Ti6-Al4-V alloy [3–5].

Next to biomedical applications, aerospace sector has dominated titanium use, instead of heavy steel components, in fabricating crucial and decisive systems such as airfoils and airframes [6–9]. About 50% of titanium used in the aerospace industry is the (α + β) alloy Ti-6Al-4V. This alloy possesses a perfect combination of operational and technological properties [10,11]. Titanium alloys have also found widespread applications in a variety of fields such as in chemical and petrochemical sectors due to their excellent corrosion resistance [12]. The outstanding characteristics (such as high specific strength, high fatigue strength, good corrosion resistance, etc.) of the titanium alloys (particularly Ti-6Al-4V) are attributed to a very stable native oxide film (1.5 – 10 nm) formed on the Ti and Ti-alloy surface upon exposure to atmosphere and/or aqueous environments [13,14]. However, this thin oxide layer can be damaged and thus strongly impacts the bioactivity and other characteristics of the material. To improve the performance of Ti and Ti-alloys for biomedical and aerospace applications, oxidation (anodization) has been applied as a successful approach to improve the material properties [15].

The microstructure, formed during various processing methods, is found to greatly affect the mechanical properties of titanium alloys [16]. The microstructure type (bimodal, lamellar and equiaxed) affects the mechanical properties of Ti based alloys [17]. Even though, the corrosion of Ti-alloys in different environments was previously studied [18,19], to the best of our knowledge, literature data revealed no reports concerning the passive layer growth kinetics and breakdown, and subsequent initiation and propagation of pitting corrosion over the surfaces of Ti-6Al-7Nb, Ti-6Al-4V, and TC21 alloys. For this reason, the main objective of this work is to shed more light on the pitting corrosion characteristics of these alloys, employing cyclic polarization and chronoamperometry measurements. In addition, the uniform corrosion behavior of these alloys was also studied based on Tafel extrapolation and EIS methods. All measurements were conducted in 0.9% NaCl solution at 37 °C.

2. Materials and Methods

The working electrodes investigated in this study consist of three Ti-based alloys, namely Ti-6Al-4V, Ti-6Al-7Nb and TC21; their chemical compositions are presented in **Table 1**. The microstructure of these alloys was studied by Meiji optical microscope fitted with a digital camera. A JEOL JSM5410 and Hitachi S-3400N scanning electron microscopes (SEM) were also used for microstructure studies. For this purpose, the specimens were prepared following ASTM E3-11 standard metallographic procedures, and then etched in a mixture of 5 mL HNO₃, 10 mL HF and 85 mL H₂O. The alloys were machined in the form of rods to perform electrochemical measurements. These rods were mounted in a polyester resin offering an active cross-sectional area of ~ 0.2 cm². Prior to conducting any electrochemical analysis, the surface of the working electrode was cleaned and polished using a silicon carbide paper (600-grit) installed on a polishing machine (Minitech 233). The surface was then washed in distilled water. Finally, an absolute ethanol was used for rinsing.

Table 1 - Chemical composition of investigated Ti alloys

Alloy	Chemical composition, wt %												
	Al	V	Nb	Sn	Zr	Mo	Cr	Si	Fe	C	N	O	Ti
Ti-6Al-4V	5.85	3.94	0.00	0.00	0.00	0.00	0.00	0.00	0.00	0.02	0.03	0.14	
Ti-6Al-7Nb	6.39	0.00	7.78	0.00	0.00	0.00	0.00	0.00	0.00	0.02	0.04	0.12	Bal.
TC21	5.89	0.00	2.41	2.51	1.59	2.27	1.58	0.067	0.05	0.01	0.01	0.13	

Electrochemical measurements were conducted in a standard, double-walled electrochemical cell with an inner volume capacity of 200 mL. Temperature of the test solution is maintained constant at the desired value by means of a temperature-controlled water bath (FP40-MA Refrigerated/Heating Circulator). The water, after being adjusted at $37 \pm 0.1^\circ\text{C}$, is allowed to circulate through external jacket of the cell. The cover of the electrochemical cell has five openings with different sizes. Such openings were designed to be fitted to the working electrode, counter electrode (a long, coiled platinum wire), reference electrode (KCl-saturated calomel electrode, SCE), a thermometer and a gas inlet/outlet for gas release. The reference electrode is placed in a Luggin capillary, the tip of which is adjusted to be close to the working electrode to minimize iR drop. The cell was connected to a Potentiostat (Autolab PGSTAT30). The test solution was a normal saline (0.9% NaCl). A Millipore Milli-Q water system (18.2 M Ω cm) was used to freshly prepare the saline solution. The salt was of analytical grade and purchased from Sigma-Aldrich.

Linear sweep voltammetry (LSV), Tafel plots, and EIS techniques were applied to investigate the uniform corrosion characteristics of the studied alloys. The susceptibility of these alloys to passivity breakdown was evaluated *via* conducting CP and CA measurements. Uniform corrosion measurements were started by stabilizing the working electrode at the rest potential for 2 h, followed by conducting EIS measurements at the respective corrosion potential (E_{corr}) every day for a week of exposure in 0.9% NaCl solution at 37°C , covering a wide frequency range (100 kHz –10 mHz), with 15 mV perturbation amplitude. Uniform corrosion study is ended by constructing Tafel plots *via* sweeping the electrode potential around the Tafel potential ($E = E_{\text{corr}} \pm 250$ mV), applying a sweep rate of 1.0 mV s⁻¹. After that, the electrode is removed from the cell (which is cleaned properly and re-filled up with a new fresh test solution), cleaned and polished up to the mirror finish, as described above, and then inserted in the cell for cyclic polarization measurements. Chronoamperometry technique was also applied using a new set of cleaned and polished electrodes submerged in a cleaned cell filled with a new fresh solution.

Prior to performing cyclic polarization technique, the working electrode is allowed to stabilize at the rest potential for 2 h, then swept linearly, with a sweep rate of 1.0 mV s⁻¹, starting from a cathodic potential of -2.0 V *vs.* SCE till +8.0 V *vs.* SCE. The potential sweep was then reversed back with the same sweep rate to reach the start point again thus, forming one complete cycle. To conduct chronoamperometry (current *vs.* time) measurements, a two-step route was applied. The working electrode is first held at a starting cathodic potential of -2.0 V *vs.* SCE for 60 s, then polarized towards the anodic direction with a sweep rate of 1.0 mV s⁻¹ till the required anodic potential (E_a). Finally, the anodic current was measured versus time (5.0 min) by holding the working electrode at E_a . To ensure results' reproducibility, each run was repeated at least three times, where mean values of the various electrochemical parameters and their standard deviations were calculated and reported.

The XRD diffraction patterns were collected for the bulk samples using a SmartLab SE (Rigaku Americas Corporation, USA) X-ray diffractometer with Cu K α ($\lambda = 1.54056$ Å) operated at 40 kV and 40 mA. The scanning speed was 0.2°/min and the scanning angle ranged from 20° to 100° in 2θ . Energy dispersive X-ray spectroscopy (EDS) measurements were utilized in order to determine microstructural composition of investigated alloys as well as evaluate changes in chemistry as a result of exposure to corrosive media. S-3400N SEM was equipped with UltraDry detector from ThermoFisher Scientific. High-resolution X-ray photoelectron spectroscopy (XPS) studies were carried out on an Escalab 250 Xi from Thermofisher Scientific, equipped with Al K α source. Pass

energy was 20 eV and the spot size diameter was 650 μm . Charge compensation was controlled through the low-energy electron and low energy Ar^+ ions emission by means of a flood gun (emission current: 150 μA , beam voltage: 2.1 V, filament current: 3.5 A). Avantage software (ThermoFisher Scientific) was used for deconvolution purposes.

3. Results and discussion

3.1. Microstructure investigation

Based on the morphology of α phase, the microstructure of titanium alloys can be classified into equiaxed, lamellar and bi-modal microstructures [20]. The microstructure of Ti-based alloys can be controlled based on their chemical composition, or in other words, based on the balance between the α phase stabilizing elements, such as Al, Sn and O, and the forming β phase elements like V, Mo and Nb [21]. As shown in **Fig. 1**, the microstructure of all studied titanium alloys consists of bimodal structure of α/β phases. The initial microstructure of Ti-Al-V and Ti-Al-Nb alloys in as-received (forged) state is represented by equiaxed grains of primary α -phase (dark), as well as β -transformed structure (light), as it can be seen in **Fig. 1**. The β phase formed in the microstructure of both alloys is globular in shape, but seems larger in size in Ti-Al-V alloy than in Ti-Al-Nb alloy. The particle size of β phase in Al-Ti-V alloy is about 0.5 to 1.5 μm ; however its size in Ti-Al-Nb alloy reaches about 0.25 to 1 μm , as shown in **Fig. 1 (a)** and **(b)**.

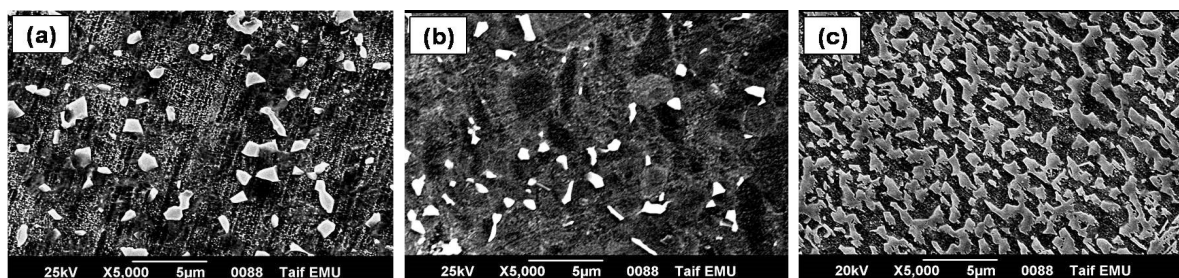


Figure 1. Microstructure of the three investigated Ti alloys: (a) Ti-Al-V, (b) Ti-Al-Nb and (c) TC21.

Similar to Ti-Al-V and Ti-Al-Nb alloys, the microstructure of TC21 alloy, **Fig. 1 (c)**, contains α and β phases, but displays different morphologies and volume fractions. The TC21 alloy's β phase consists of two shapes; the first one is acicular-like structure, **Fig. 2 (a)**, while the other one is a blocky shape, **Fig. 2 (b)**. The thickness of the acicular β phase in the TC21 alloy's microstructure is ranging from around 0.2 to 0.6 μm , while the size extent of the blocky β phase is about 0.75 to 1.5 μm . Moreover, the volume fraction of β phase in the microstructure of TC21 alloy is higher than that in the Ti-Al-V and Ti-Al-Nb alloys' microstructure, as depicted in **Fig. 1**.

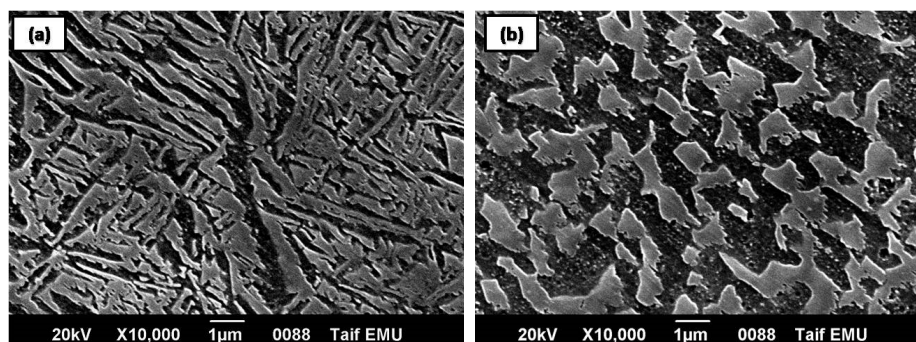


Figure 2 - Morphology of β phase in TC21 alloy: (a) acicular-like structure and (b) blocky shaped structure

Table 2 illustrates the volume fraction of α and β phases in the microstructure of the studied titanium alloys. The microstructure of pure Ti has the highest volume fraction of the α phase (~100%) and the lowest volume fraction of β phase (~0.0%). The presence of Al (α -phase stabilizer) and V (β -phase stabilizer) as alloying elements in the chemical composition of Ti-Al-V alloy influence the volume fraction of α and β phases. The values of the volume fractions of α and β phases (**Table 2**) in the microstructure of Ti-Al-V alloy were 65% and 35%, respectively. Replacing V with Nb, yielding Ti-Al-Nb alloy, resulted in an obvious enhancement in the volume fraction of α phase (increased to 77%) at the expense of that of the β phase, which decreased to 23%, as shown in **Table 2**. The volume fraction of both phases in the microstructure of TC21 alloy is also altered, most probably due to the mutual combination of the alloying elements of that alloy, revisit **Table 1**. The volume fractions of α and β phases in the microstructure of TC21 alloy recorded almost equal values, namely 48% for α phase and 52% for β phase (**Table 2**).

Table 2 - Volume fraction of α and β phases in the investigated Ti based alloys.

Alloy	Volume fraction, %		(α/β) ratio
	α phase	β phase	
Pure Ti	100	0	--
Ti-6Al-4V	65	35	1.86
Ti-6Al-7Nb	77	23	3.35
TC21	48	52	0.92

To further assess the influence of chemical composition on the microstructure and volume fraction of α and β phases, $[Al]_{eq}$ and $[Mo]_{eq}$ were calculated, where $[Al]_{eq}$ and $[Mo]_{eq}$ represent the alloying elements form α and β phases [5,22]. **Table 3** illustrates the calculated values of $[Al]_{eq}$ and $[Mo]_{eq}$ for the tested Ti-based alloys, following Eqs. 1 and 2 [5,22].

$$[Al]_{eq} = [Al] + 0.33[Sn] + 0.17[Zr] + 10[O+C+2N] \tag{1}$$

$$[Mo]_{eq} = [Mo] + 0.2[Ta] + 0.28[Nb] + 0.4[W] + 0.67[V] + 1.25[Cr] + 1.25[Ni] + 1.7[Mn] + 1.7[Co] + 2.5[Fe] \tag{2}$$

Table 3 - $[Al]_{eq}$ and $[Mo]_{eq}$ for the investigated alloys [22,23].

Alloy	$[Al]_{eq}$	$[Mo]_{eq}$	Ratio
TiAlV	8.05	2.64	3.05
TiAlNb	8.59	2.18	3.94
TC21	8.59	5.04	1.71

It follows from **Table 3** that TiAlNb and TC21 alloys recorded the highest values of $[Al]_{eq}$, 8.59, while the lowest values were measured for the TiAlV alloy, 8.05. Additionally, TiAlNb alloy achieved the maximum value of $[Mo]_{eq}$, 3.94, whilst TC21 alloy recorded 1.71. **Table 3** also depicts the ratio $[Al]_{eq}/[Mo]_{eq}$ for the tested alloys. TiAlNb alloy displayed the maximum ratio, 3.94, while a minimum ratio of 1.71 was measured for the TC21 alloy. It is obvious that the results obtained from **Table 3** agree well with the results in **Table 2**. The calculated ($[Al]_{eq}/[Mo]_{eq}$) and (α/β) ratios are maximum in case of TiAlNb alloy, and minimum for the TC21 alloy.

The chemical composition of both phases in all microstructures of the investigated alloys was analyzed using the EDS unit attached to SEM. The EDS spectrum recorded for β phase in the microstructure of Ti-Al-V alloy is depicted in **Figure S1 (b)** (**Supporting Information**). The location of the area of analysis is illustrated in **Figure S1 (a)**. The highest peak in the spectrum belongs to the base metal (Ti), in addition to some other peaks from Al and V alloying elements. Similarly, the analyses of the two phases in other microstructures were accomplished. Results of these analyses are

depicted in **Tables 4** and **5**. From the results in **Tables 4** and **5**, it is evident that the Ti, Al, Sn and Zr elements tend to segregate to α phase than to β phase [23]. However, V, Nb, Cr and Mo are β forming elements [24], meaning that higher ratios of these elements are found in β phase rather than in α phase.

Table 4 - Chemical composition (wt %) of different phases in Ti-Al-V and Ti-Al-Nb alloys.

Phase	Ti-Al-V alloy (wt %)			Ti-Al-Nb alloy (wt %)		
	Al	V	Ti	Al	Nb	Ti
α	5.93	3.24	90.83	6.60	7.65	85.75
β	5.57	8.04	86.39	4.88	13.79	81.33

Table 5 - Chemical composition (at %) of different phases in TC21 alloy.

Phase	Chemical composition, at %						
	Al	Cr	Mo	Sn	Zr	Nb	Ti
α	6.38	1.08	1.82	2.45	1.95	1.98	84.34
β	6.21	1.71	2.62	2.24	1.11	2.39	83.72

The line analysis through β phase is shown in **Figure S2 (Supporting Information)**. The phase β is surrounded by the equiaxed α phase in the microstructure of Ti-Al-Nb alloy. The distribution of different alloying elements, Ti, Nb and Al, is illustrated throughout these two phases. The highest line, in green color, represents the distribution of Ti and the grey line shows that of Nb. Additionally, the third one, in pink color, displays the line analysis of the Al element. Obviously, the β phase has lower Ti and Al contents than the α phase, while it has higher amount of Nb compared to α phase. The distribution of alloying elements such as Ti, Al and Nb in Ti-Al-Nb alloy is depicted in **Figure S3 (Supporting Information)**. Mapping analysis for the bimodal α/β microstructure of Ti-Al-Nb alloy is exhibited in **Figure S3 (a), Supporting Information**, where a clear β phase surrounded by equiaxed α phase is observed at higher magnification, 20000 \times . **Figure S3 (b-d), Supporting Information**, illustrates the segregation of Ti, Al and Nb alloying elements, respectively. The distribution of these elements between α and β phases is represented by the density of different colors. The rich areas of Ti, Al and Nb elements are decorated by red color, while the poor areas are painted with dark color. In case of Ti element, as it preferably segregated to α phase, as shown in **Figure S2 (Supporting Information)**, the area of α phase is colored with a combination of red, yellow and pink, however the β phase area, with lower Ti content, has a dark color, see **Figure S3 (b), Supporting Information**. The contrast for the partitioning of Al alloying element between α and β phases is not as clear as in the case of Ti element, **Fig. S3 (c), Supporting Information**. In addition to the distribution of Ti and Al, the segregation of Nb alloying element, with lower percentage, to α phase is represented by a combination of green, blue and black colors, while the area of the β phase with higher Nb content is decorated by a mixture of red and white colors, as shown in **Figure S3 (d), Supporting Information**.

3.2. X-Ray diffraction studies

Phase identification was performed by X-ray diffraction (XRD) patterns to define the phases comprising each alloy sample. The diffraction patterns recorded for the studied alloys are compared all together in **Fig. 3**. The phases were identified by matching the characteristic peaks with the JCPDS files [25]. The phases α -Ti (JCPDS#00-044-1294), β -Ti (JCPDS#00-044-1288) were common and dominated the composition of the three studied alloys. The Ti-Al-V and TC21 alloys were found to contain solely α -Ti and β -Ti phases, respectively. On the other hand, Ti-Al-Nb alloy contained some Ti and Nb oxides, TiO (JCPDS#00-008-0117) and Nb₂O (JCPDS#00-015-0258).

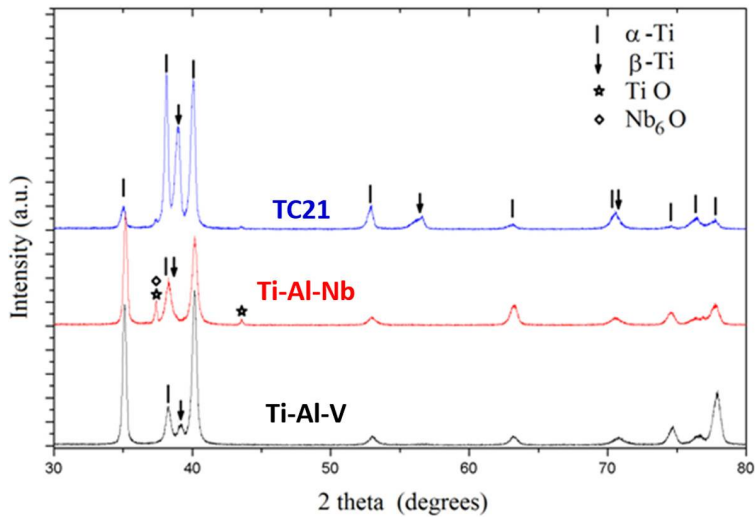


Figure 3 - XRD diffraction patterns recorded for the samples Ti-6Al-4V, Ti-6Al-7Nb and TC21.

Table 6 - The structural and microstructural parameters of the three alloys obtained by the Rietveld adjustment of the XRD patterns.

Ti-6Al-4V				
	α -Ti ($P6_3/mmc$)	β -Ti ($Im\bar{3}m$)		
Wt%	67(5)	33(5)		
a (Å)	2.9338(1)	3.2353(9)		
c (Å)	4.6780 (3)			
D (nm)	76(3)	67(4)		
ϵ	0.00232(1)	0.00216(4)		
Ti-6Al-7Nb				
	α -Ti ($P6_3/mmc$)	β -Ti ($Im\bar{3}m$)	TiO ($Fm\bar{3}m$)	Nb6O ($P4_2cm$)
Wt%	73(6)	20(5)	5(2)	2(1)
a (Å)	2.9397(4)	3.2437(5)	4.1567(1)	3.3945(6)
c (Å)	4.6969(3)			3.249(3)
D (nm)	67(2)	53(2)	79(12)	100(2)
ϵ	0.0028(1)	0.024(20)	0.0026(1)	0.00010(7)
TC21				
	α -Ti ($P6_3/mmc$)	β -Ti ($Im\bar{3}m$)		
Wt%	49(9)	51(9)		
a (Å)	2.9407(7)	3.2521(14)		
c (Å)	4.6925(16)			
D (nm)	63(2)	70(3)		
ϵ	0.0021(2)	0.0035(3)		

An effective procedure for the simultaneous refinement of structural and microstructural parameters based on the integration of Fourier analysis for broadened peaks in the Rietveld method was first proposed by Lutterutti et al. [26] and is implemented in the Maud program [27]. Consequently, weight percent (wt.%), lattice parameters, isotropic crystallite size (D) and r.m.s microstrain ($\mu\epsilon$) were then regarded as fitting parameters in the Rietveld adjustments and were refined altogether simultaneously. The structural information for all the refined phases was obtained

from the ICSD database [28]. The results obtained for the structural and microstructural analysis are summarized in **Table 6** for all alloys. It is worth to mention here that, all studied alloys were characterized with considerable degree of preferred orientation which strongly modified the relative intensities of the Bragg reflections, especially for α -Ti and β -Ti phases. The MAUD program also incorporates correction for preferred orientation [29,30] in the Rietveld adjustments in order to obtain the best fitting parameters.

The calculated diffraction patterns from the Rietveld adjustment are plotted with the observed ones for the three alloys in **Fig. 4**. The average R-values obtained for the refinements were about $R_{wp}(\%) = 24$ to 27 and $R_b(\%) = 15$ to 20. The simultaneous refinements of both structural and microstructural parameters produced good matching of the calculated to observed profiles of diffracted intensities. Also, the incorporation of the preferred orientation models enabled to account for the variations of the peak intensities of α and β -Ti phases.

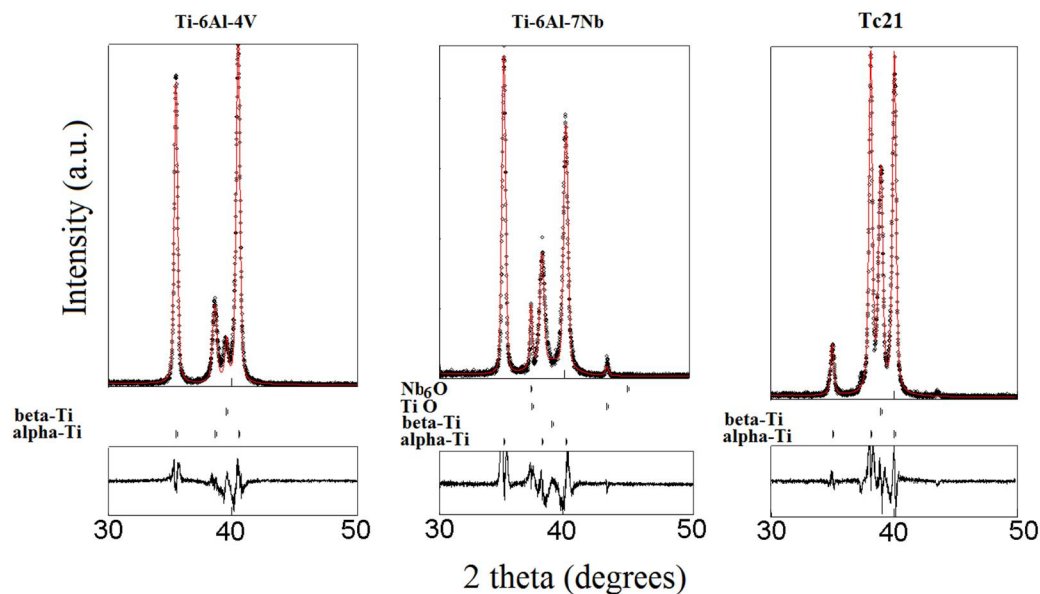


Figure 4 - The calculated (red line) and observed (black dots) diffraction patterns for the three alloys as obtained from the Rietveld adjustments using the MAUD program; the positions of the Bragg reflections of each phase and the difference between the calculated and observed patterns are also presented at the bottom.

In the Rietveld adjustment of the alloy Ti-Al-V, the hcp α -Ti (Space group $P6_3/mmc$) together with the bcc β -Ti (Space group $Im\bar{3}m$) dominated the composition of the alloy. In the second alloy, Ti-Al-Nb, the formation of some TiO (Space group $Fm\bar{3}m$) and Nb₆O (Space group $P42cm$) was observed and they form larger crystallites than those formed in the Ti phases. The total weight percent of those oxide phases is less than 10% (**Table 6**). For the third alloy, TC21, only α and β -Ti phases were observed in the XRD patterns. No oxide phases were detected due to the slight oxygen content of this alloy. Nevertheless, there are some mismatches between the wt% values obtained from the Rietveld adjustments and the corresponding wt% values obtained with other techniques. This can be attributed to the behavior of the preferred orientation of the α -Ti phase observed for the reflection (100), which was relatively stronger for the Ti-6Al-4V and Ti6Al7Nb alloys than in the TC21 alloy.

As can be seen from **Table 6**, the last two alloys, Ti-Al-Nb and TC21, contain relatively higher portions of β -Ti than α -Ti in contrast to the first alloy, Ti-Al-V, which has α -Ti content higher than β -Ti. As known from literature, Al is an α -stabilizing while V, Nb, Mo and Fe are β -stabilizing. Nevertheless, the results indicate that Nb, Mo and Fe have stronger capabilities to stabilize β -Ti phase than V. These findings corroborate microstructural studies (revisit section 3.1).

3.3. Electrochemical measurements

3.3.1. Uniform corrosion studies

Figure 5 illustrates the Tafel plots for the cathodic and anodic domains for the studied alloys in comparison with pure Ti, after 7 days of immersion in 0.9% NaCl solution at 37 °C. **Table 7** depicts the various electrochemical parameters derived from such polarization measurements. It follows from **Fig. 5** that, among the studied alloys, TC21 alloy exhibited the lowest cathodic and anodic overpotentials, corresponding to increased corrosion current density (j_{corr}) values. This is clear from **Table 7**, which revealed that TC21 alloy recorded a j_{corr} value of 0.32 mA cm⁻², which is 940, 640, and 320 times greater than those measured for pure Ti (3.4×10^{-4} mA cm⁻²), Ti-Al-Nb (5×10^{-4} mA cm⁻²), and Ti-Al-V alloys (10^{-3} mA cm⁻²), respectively. These findings reveal that the rate of the uniform corrosion of the studied alloys increases following the order: Ti < Ti-Al-Nb < Ti-Al-V << TC21.

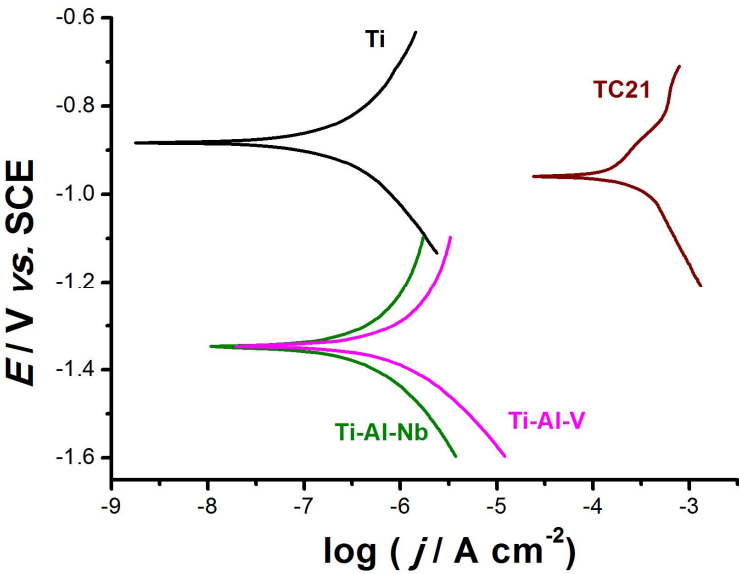


Figure 5 - Cathodic and anodic polarization curves recorded for the three tested alloys in comparison with pure Ti, after 7 days of exposure in 0.9% NaCl solution at a scan rate of 0.5 mV s⁻¹ at 37 °C.

Table 7 - Mean values of the various electrochemical parameters obtained from Tafel extrapolation method for pure Ti and the three tested alloys after 7 days of exposure in 0.9% NaCl solution at 37 °C.

Tested alloy	$E_{\text{corr}} /$ mV(SCE)	$\beta_c /$ mV dec ⁻¹	$\beta_a /$ mV dec ⁻¹	$j_{\text{corr}} /$ mA cm ⁻²
Pure Ti	-880	-296	400	3.4×10^{-4}
Ti-Al-Nb	-1350	-120	240	5×10^{-4}
Ti-Al-V	-1340	-240	480	10^{-3}
TC21	-960	-400	560	0.32

EIS measurements were also conducted at the respective E_{corr} throughout the exposure in 0.9% NaCl solution at 37 °C to confirm the polarization data and to assess the kinetics of the uniform corrosion process on the surfaces of the tested alloys. **Fig. 6** displays the impedance plots in Nyquist projection, recorded for the studied alloys. Pure Ti (99.99%) was also included for comparison. Plotting time of exposure on X-axis of impedance diagrams allowed for monitoring of uniform corrosion susceptibility [31–33]. It can be observed that in each case the impedance spectra recorded at day 1 (after initial 120 min of conditioning) were highly scattered due to non-stationary conditions at the metal/electrolyte interface, which is a common problem in EIS measurements. This issue became negligible after a few hours of exposure. For this reason, results recorded at day 2-7 will be

taken for further analysis. The impedance loop appeared as an open arc with a big diameter (charge-transfer resistance, R_{ct}), hence the overall corrosion resistance of each investigated alloy is very high. Ti-6Al-4V and Ti-6Al-7Nb alloys seem to be stable over time of the exposure, with Ti-6Al-7Nb alloy being more corrosion resistant than Ti-6Al-4V alloy, while the results obtained for TC21 reveal gradual decrease of the impedance loop, corroborating DC electrochemical studies.

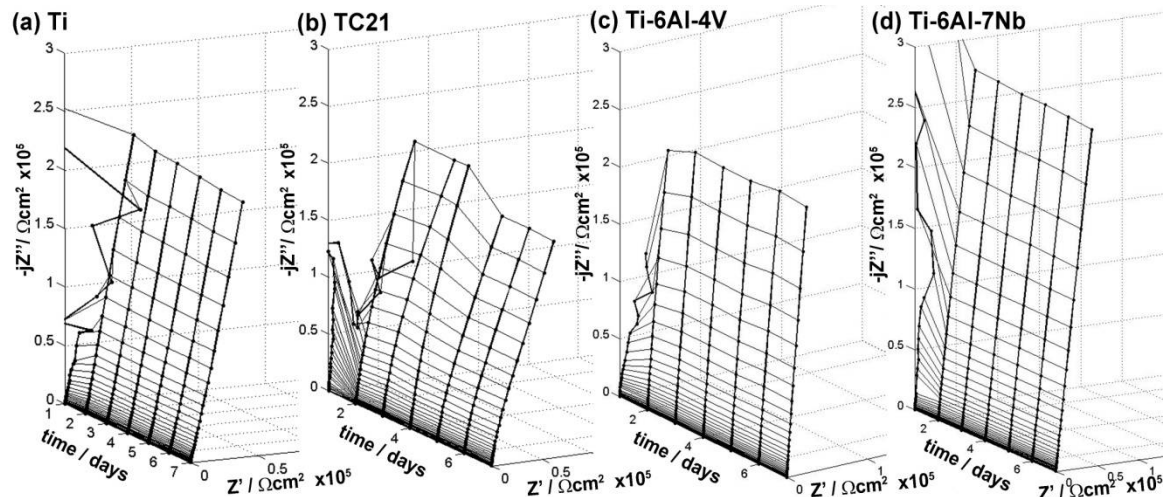


Figure 6 - Nyquist impedance plots recorded for the three tested alloys in comparison with pure Ti at the respective E_{corr} in 0.9 % NaCl solution at 37 °C. The changes in spectra shape with exposure time (7 days) can be tracked on X-axis.

All impedance plots showed a single time constant (capacitive loop), which can be verified on the corresponding Bode plots after 7 days of exposure (Fig. 7). An electric equivalent circuit (EEC) was proposed to analyze the impedance results. Due to absence of additional time constants, a simple Randles circuit was proposed with constant phase element (CPE) selected instead of capacitance to take into consideration surface distribution of capacitance dispersion. The parallel resistance represents the charge-transfer resistance R_{ct} through the metal/electrolyte interface [34].

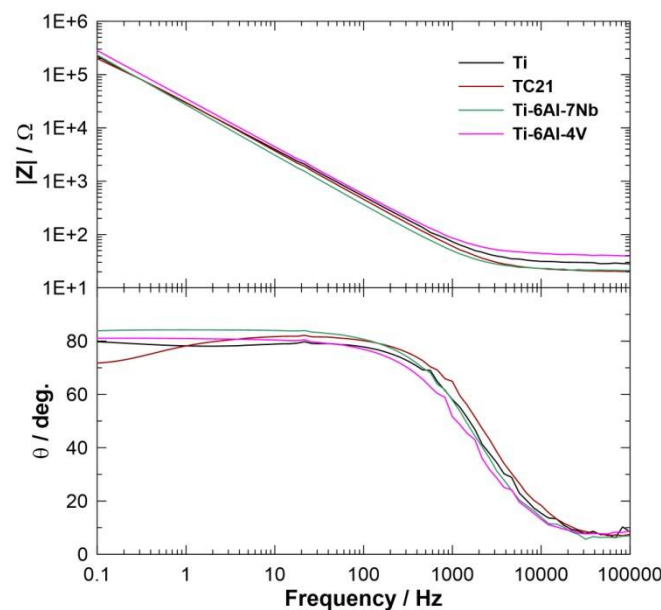


Figure 7 - Bode plots of each investigated alloy on the day 7 of exposure in comparison with pure Ti (99.99%) at the respective E_{corr} in 0.9 % NaCl solution at 37 °C.

The aforementioned capacitance dispersion may in particular originate from geometric heterogeneity (pits, scratches, porosity) as well as diversified surface electric properties due to

adsorption processes of passive layer breakdown [35]. The CPE impedance $Z_{CPE} = (Q(j\omega)^n)^{-1}$ represents a capacitor with capacitance $1/Q$ for a homogeneous surface $n \rightarrow 1$. Thus, it is often believed that CPE component n is the heterogeneity factor and its variation can be monitored. CPE describes quasi-capacitive behaviour of passive layer in case of its double layer perforation. The effective capacitance C_{eff} can be calculated on the base of CPE using Hirschorn's model for surface distribution of time constants [36]. The EEC can be schematically written as $R_s(QR_{CT})$, where R_s is electrolyte resistance. The aforementioned single time-constant EEC covers all the applied frequency range.

Fig. 8 depicts the electric parameters obtained on the base of $R_s(QR_{CT})$ EEC and their changes during the one-week long exposure. The higher the R_{CT} the lower the corrosion current density, offering an easy comparison in uniform corrosion resistance of investigated alloys, see **Fig. 8a**. Each investigated alloy is characterized with very high resistance, range of $M\Omega$, owing to a presence of a passive layer tightly covering metal surface. Nevertheless, for TC21 alloy, R_{CT} value is one order of magnitude lower and slowly but consistently decreases throughout the exposure, revealing its lower corrosion resistance. High scatter of R_{CT} value is inversely proportional to measured fraction of impedance semicircle (as seen on **Fig. 6**).

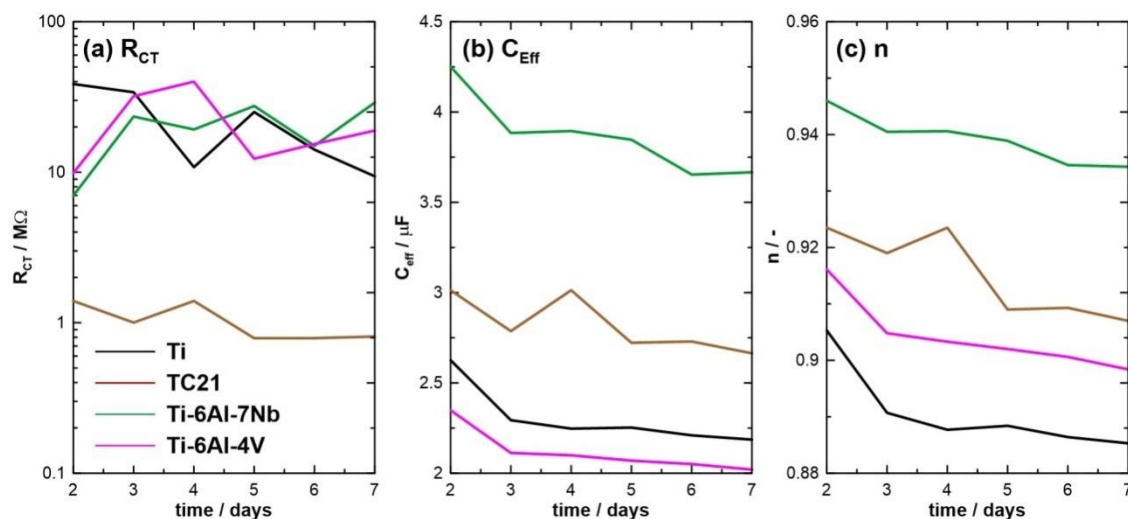


Figure 8 - Charge transfer resistance R_{CT} , effective capacitance C_{eff} and CPE exponent n calculated on the base of $R_s(QR_{CT})$ EEC for each investigated alloy. The one-week long exposure was carried out in 0.9 % NaCl solution at 37 °C.

The analysis of constant phase element (CPE) allows to draw conclusions on passive layer homogeneity. The effective capacitance C_{eff} , calculated with surface distribution model is similar for each investigated alloy, falling in a range between 2 and 5 μF . The differentiation may result from differences in passive layer thickness d and to some extent from relative permittivity of alloying additives and their oxides ϵ_r according to: $C = \epsilon_0 \epsilon_r d / A$, where ϵ_0 is the absolute permittivity and A is the electrochemically active surface area. A steady decrease of C_{eff} should be attributed to an increase of passive layer thickness, denouncing further passivation of metal in investigated electrolytic conditions. The presence of stable corrosion pits would be visible in a form of rapid increase in C_{eff} [36,37] (likely observed at TC21 alloy at day 4).

The initial value of CPE exponent n depends on factors such as surface phase distribution and geometric defects remaining as a result of polishing. Its decrease throughout the exposure in corrosive electrolyte reflects the appearance of heterogeneities on analyzed sample surface, which in this case is primarily associated with initial phases of corrosion pits formation (see **Fig. 8c**). This effect is clearly seen on SEM micrographs further in the manuscript. Notably, the value of n factor of Ti-6Al-7Nb alloy was both: the highest as well as the least affected by exposure in corrosive media. The aforementioned observation indicates high surface homogeneity, which may be the reason behind outstanding corrosion resistance of this alloy.

3.3.2. Cyclic polarization measurements

Figure 9 shows typical cyclic polarization curves in the linear (E vs. j) and logarithmic (E vs. $\log j$) formats recorded for the studied alloys between -2.0 V and $+8.0$ V (SCE). Measurements were conducted in 0.9% NaCl solution at a scan rate of 5.0 mV s^{-1} at 37°C . The logarithmic form of these curves (E vs. $\log j$), **Fig. 9 (b)**, is also constructed to define precisely the location of the pitting potential (E_{pit}) and repassivation potential (E_{rp}) versus the corrosion potential (E_{corr}). **Fig. 9 (a₁)** is zoomed with a very narrow range of current around the cathodic and anodic processes covering the whole studied potential range to yield **Fig. 9 (a₂)**. It follows from **Fig. 9 (a₂)** that, for all tested samples, the cathodic current density diminishes progressively reaching its zero value at the corrosion potential (E_{corr}).

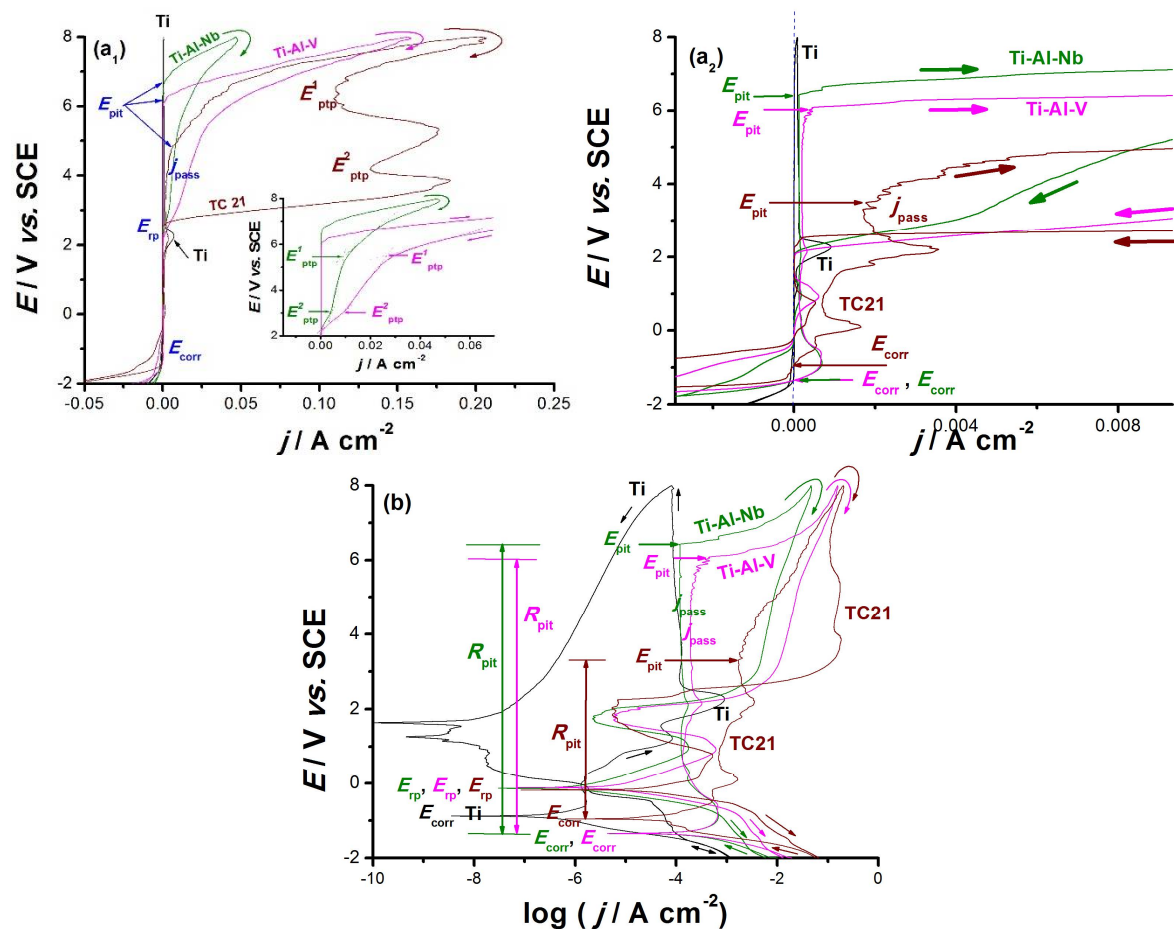


Figure 9 - Linear, (a₁) and (a₂), and logarithmic (b) cyclic polarization curves recorded for the studied alloys in 0.9% NaCl solutions at a scan rate of 1.0 mV s^{-1} at 37°C .

The polarization curve of TC21 alloy exhibits active dissolution near E_{corr} , followed by an obvious enhancement in the anodic current with the applied potential due to thinning and weakening of the passive layer as a result of the aggressive attack of Cl^- anions. Also, Ti-Al-Nb and Ti-Al-V alloys show active dissolution near E_{corr} , but to a much lower extent than TC21, and in addition, tend to passivate with a very low current (passive current, j_{pass}) covering a wide range of potential. These findings reflect the weaker passivity of TC21 and its higher tendency to corrode in this solution than Ti-Al-V and Ti-Al-Nb alloys. On the contrary, as expected, the anodic polarization curve of pure Ti exhibits typical passivity near E_{corr} , referring to its high corrosion resistance.

Passivity of the studied alloys persists up to a certain critical potential, designated here as the pitting potential (E_{pit}). Remarkable changes occur within the passive region at potentials exceeding E_{pit} . These involve a sudden increase in j_{pass} and formation of a hysteresis loop on the reverse

potential scan. These events are a clear sign for passivity breakdown, and initiation and propagation of pitting corrosion.

In general, the electrochemical systems suffering from pitting corrosion are characterized by a hysteresis loop in their cyclic voltammograms. Such a loop refers to the continuation of pitting corrosion even after potential scan reversal (pitting corrosion's autocatalytic nature), indicating repassivation delay of the existing pits. Repassivation is only achieved when the reverse scan intersects the forward one within the passive region in a point designated here as the repassivation potential, E_{rp} , below which the working electrode is immune against pitting. Others defined it as the potential below which no pit could grow, or in other words, a pit once initiated, will stop [38].

A current intermission can be seen on the reverse scan of the three tested alloys. This current discontinuity is quite clear on the reverse scan of the TC21 alloy, and can be observed for alloys Ti-Al-Nb and Ti-Al-V in the inset of **Fig. 9 (a)**. It takes place at two distinct potentials (E_{1ptp} and E_{2ptp}), designated here as the pit transition potential (E_{ptp}), the potential between bare and salt-covered state, where diffusion control dominates beyond E_{ptp} [38]. We previously reported similar findings during pitting corrosion studies of Zn in nitrite solutions [39] and recently by Zakeri et al. [40], who explored the transition potential and the repassivation potential of AISI type 316 stainless steel in chloride containing media devoid of and containing 0.01 M thiosulfate.

At potentials beyond E_{ptp} , the rate of anodic dissolution is diffusion-controlled (controlled by diffusion of metal cations from the salt/pit solution interface into the bulk solution) [38–40]. Such a current transient relationship, when satisfied, refers to an anodic diffusion control process [40]. On reversing the potential scan, the thickness of the salt (pitting corrosion product) film diminishes. This decrease in salt film thickness enhances with back scanning till a certain potential is reached at which the cations' concentration decreases below the saturated concentration. At this stage, salt precipitation is stopped, and the remaining metal salt film will be dissolved, making the bottom of pits free from salt film. This in turn will establish an ohmic/activation control (a linear decrease of current density with potential) regime.

Ti-Al-Nb alloy's passivity seems stronger and more stable than that of the Ti-Al-V alloy, **Fig. 9 (b)**. The latter is characterized by a higher j_{pass} which enhances with potential till its E_{pit} , which attained ~ 50 mV vs. SCE before that of the former. In addition, the pits existing on the surface of Ti-Al-V alloy find it much more difficult to repassivate than those on the surface of Ti-Al-Nb alloy, as the hysteresis loop of the former is much larger than that of the later.

Another important pitting corrosion controlling electrochemical parameter is the pitting corrosion resistance, R_{pit} ($R_{pit} = |E_{corr} - E_{pit}|$), which defines the resistance against the nucleation of new pits [38]. Referring to **Fig. 9 (b)**, it is clear that R_{pit} increases following the order: TC21 << Ti-Al-V < Ti-Al-Nb. The resistance against growth of the pits also controls the susceptibility toward pitting corrosion. This can be evaluated via comparing the areas of the hysteresis loops formed during the reverse potential scan of the cyclic polarization curves in its linear format, **Fig. 9 (a)**. A specific routine of the Software was used to calculate the areas of the hysteresis loops, related to the charge consumed during the growth of such already formed pits. Here again, the hysteresis loop of the TC21 alloy recorded the highest area (charge consumed) among the studied alloys, while the lowest value of the hysteresis loop's charge consumed during was measured for Ti-Al-Nb alloy. This in turn ranks the resistance against the growth of pre-existing pits as Ti-Al-Nb > Ti-Al-V >> TC21. These findings mean that replacing V by Nb in Ti-Al-V alloy promotes alloy's repassivation thus, enhancing its pitting corrosion resistance.

3.3.4. Chronoamperometry measurements

Chronoamperometry (j/t) measurements were also carried out to confirm the above results and gain more information about the influence of alloyed V and Nb on the passive layer growth kinetics and breakdown. **Figs. 10 (a) and 10 (b)** depict the j/t curves measured for the tested alloys at two different E_a values, far below and close to E_b . Measurements were conducted in 0.9% NaCl solution at 37 °C. The profile of the obtained curves is found to vary according to the chemical composition of the studied alloy and the position of E_a versus E_b . When E_a is located far cathodic to E_b , a j/t profile

with two stages is obtained, as shown in **Fig. 10 (a)**. During the first stage, the anodic current (j_a) declines with a rate depending upon chemical composition of the tested alloy, denoting passive layer electroformation and growth [39]. This decay in current then reaches a steady-state value (j_{ss}), an almost constant passive current related to j_{pass} (revisit **Fig. 9**), constituting the 2nd stage of the current. The constancy of j_{ss} originates from a balance between the rates of the passive layer growth (current builds up) and its dissolution (current decays) [41,42].

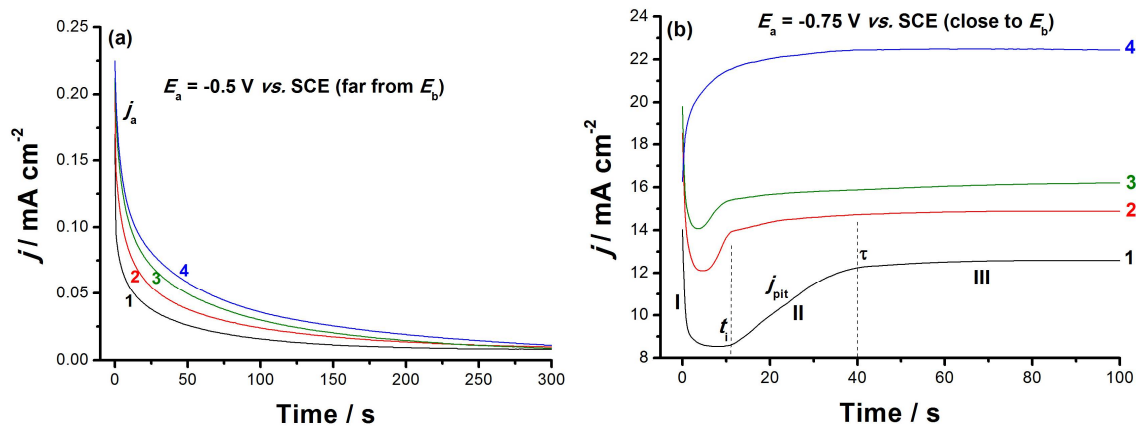


Figure 10 - Chronoamperometry (current - time) curves recorded for the studied solder alloys in 0.9% NaCl solution at applied anodic potentials of 2.0 and 4.0 V vs. SCE at 37 °C: (1) pure Ti; (2) Ti-6Al-7Nb; (3) Ti-6Al-4V; (4) TC21.

Further snooping of **Fig. 10 (a)** demonstrates that the rate of j_a decay, and consequently the rate of passive layer growth, diminishes upon alloying Ti with V and Nb. These results further confirm the acceleration influence of the alloying elements V and Nb, with V being more active than Nb, which when added to Ti weakened its passivity *via* depassivation (destabilizing the passive oxide film through oxide film thinning/dissolution [43]). This in turn makes the passive film more susceptible to pitting.

At the E_a value that is very close to E_b , **Fig. 10 (b)**, j/t curves with three different stages (I-III) were obtained. Similar results were previously obtained in our lab [42,44]. Stage I referred to the passive layer electroformation and growth, as its current falls with time [41,42,44]. This stage, namely stage I ends at a certain time (t_i), the incubation time, where stage I's current reached its minimum value; t_i is defined as the time the adsorbed aggressive Cl⁻ anions must acquire to locally attack and subsequently remove the passive oxide film [41]. The magnitude of t_i , more specifically its reciprocal value ($1/t_i$), denotes the rate of pit initiation and growth [41,42], and measures the susceptibility of the oxide film to breakdown and initiate pit formation and growth.

Stage II begins at t_i and terminates at another time τ , and its current is termed j_{pit} (pit growth current density). j_{pit} increases from the moment just after t_i and continues in growth till τ , suggesting that the pit formation and growth dominate over passivation during this stage. Ultimately, j_{pit} attained a steady-state just after the time τ , denoting the onset of stage III, and continues almost constant till the end of the run. The constancy of the stage III's current was attributed to the hindrance of the current flow (j_{pit}) through the pits sealed off by the pitting corrosion products formed during the events of stage II, namely pit initiation and growth [42,44]. This hindrance in j_{pit} is balanced by a current increase due to metal dissolution, thus yielding an overall steady-state current.

Close inspection of **Fig. 10** reveals that j_{pit} increases and t_i gets shorter, thus referring to accelerated pitting attack, in presence of alloyed V. These results again support the catalytic impact of alloyed V towards pitting corrosion

3.4. Surface morphology and composition

After one-week exposure, investigated samples were reexamined using SEM in order to evaluate the susceptibility to pitting corrosion. This procedure was carried out after rinsing in ethanol using ultrasonic cleaner. The results of the analysis are exhibited on **Fig. 11**. Defects start to appear at the surface of each analyzed sample throughout the exposure. The micrographs in the inset of **Fig. 11** were taken using back-scatter electrons (BSE) in topography mode. This allowed to bring out the geometry of aforementioned defects. As can be seen, each analyzed defect forms shape of a bulge above alloy's surface, testifying for either repassivation once formed shallow corrosion pits or at an early, preliminary stage of passive layer degradation. Ti-6Al-4V sample is characterized with both the highest amount and the largest defects, reaching 30 μm in diameter. On the other hand, the surface of pure Ti and Ti-6Al-7Nb appeared the most intact. No real corrosion pits were observed on the surface of either investigated alloy at the end of exposure in 0.9% NaCl solution at 37 °C, testifying for the overall high pitting corrosion resistance.

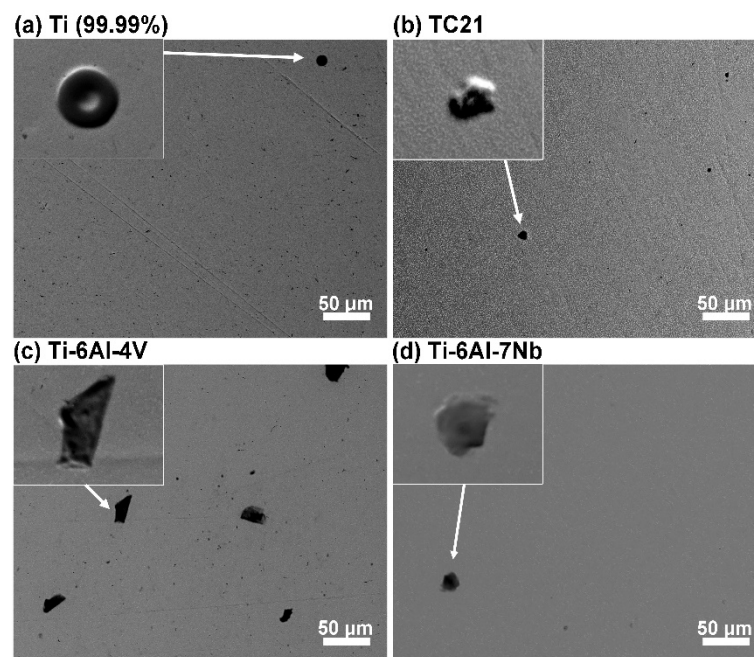


Figure 11 - SEM micrographs taken in secondary electron mode for each investigated sample: (a) pure Ti as a reference, (b) TC21 alloy, (c) Ti-6Al-4V, (d) Ti-6Al-7Nb at the end of one-week long exposure in 0.9% NaCl at 37 °C. Magnification $\times 500$. In the inset back-scatter electron topography mode images of selected surface defects. Magnification $\times 2000$.

Nevertheless, the passive layer must have weakened hence it was possible for corrosion products to adsorb on the metal surface. EDS analysis was carried out for defects observed on each investigated alloy in order to qualify their chemical constitution. The exemplary results, obtained for Ti-6Al-7Nb alloy are summarized on **Figure S4 (Supporting Information)**, while the chemistry of defects observed for each investigated alloy were similar. The defects are primarily composed of carbon and oxygen, most likely forming metal carbonates typical for early pitting corrosion stages [45]. Small amount of chlorine was also recorded within defects. Its low amount is distorted by EDS depth of analysis ranging few microns.

The chemistry of the passive layer in each examined case is composed primarily of titanium (IV) oxides, as verified by a strong recorded Ti_{2p} peak doublet, with $\text{Ti}_{2p_{3/2}}$ component located each time at 458.6 eV [35,46,47], **Fig. 12**. Furthermore, there is no sign of titanium oxides at lower oxidation states corroborating the aforementioned result. Besides the titanium, other alloying additives also take part in passivation process. The strongest signal among the alloying additives was recorded for aluminum oxide Al_2O_3 ($\text{Al}_{2p_{3/2}}$ peak at 74.5 eV), ranging between 3.5 and 3.8 at.% for each sample [48,49]. The contribution of VO_2 ($\text{V}_{2p_{3/2}}$ at 516.4 eV) in Ti-Al-V and Nb_2O_5 ($\text{Nb}_{3d_{5/2}}$ at 207.1 eV) in Ti-Al-Nb alloy did not exceed 0.7 at.% [47,50,51]. The passive film formed on the surface of TC21

alloy is naturally more complex. Besides TiO₂, it is composed of Al₂O₃ (3.8 at.%), Nb₂O₅ (0.3 at.%), ZrO₂ (0.4 at.%, Zr_{3d5/2} at 182.4 eV), Cr₂O₃ (0.8 at.%, Cr_{2p3/2} at 576.0 eV), SnO₂ (0.1 at.%, Sn_{3d3/2} at 486.5 eV), MoO₃ and MoO₂ (0.2+0.2 at.%, Mo_{3d5/2} at 232.9 and 229.2 eV, respectively) [52–55].

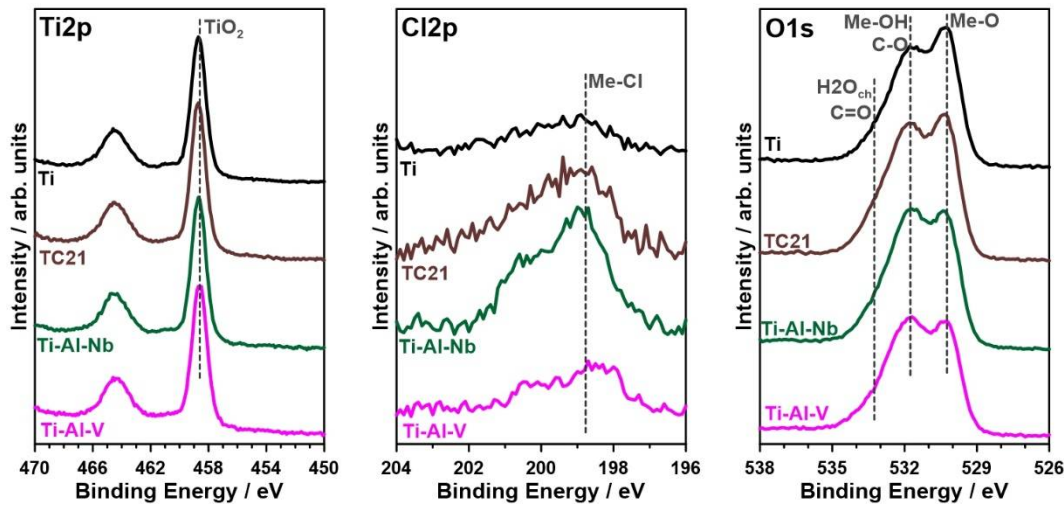


Figure 12 – High-resolution XPS spectra recorded in Ti_{2p}, Cl_{2p} and O_{1s} energy range for each investigated alloy after 7 days of exposure to 0.9% NaCl solution at 37 °C.

The high-resolution spectra analysis carried out in the Cl_{2p} energy range confirms the electrochemical and microscopic studies regarding chloride adsorption on the metal surface as a result of 7-day metal exposure to chloride-containing electrolyte. Full chemical analysis is summarized in **Table 8**. Metal chlorides were found on the surface of each investigated sample, which confirms metal-chlorine covalent bond formation, testified by a peak doublet: Cl_{2p3/2} at 198.9 eV [35,42,56]. Nevertheless, the amount of adsorbed chlorides is nearly 2.5 times higher for the TC21 alloy than pure titanium. The chloride concentration obtained for highly resistant Ti-Al-Nb alloy is nearly on par with Ti sample, and slightly smaller than in the case of Ti-Al-V. An interesting conclusion may be drawn based on O_{1s} peak analysis for each investigated sample. The spectra were conventionally deconvoluted into three components. Two dominant components located at 530.2 and 531.6 eV are ascribed to Me-O and Me-OH species, respectively. The second component intensity may be further influenced by presence of C-O bonds in carbonates. Its formation may result from prolonged electrolyte exposure but also adventitious carbon formation due to air exposure [48,51]. The finding regarding carbonates adsorption on the metal surface is further confirmed by third O_{1s} component at 532.8 eV, typical for C=O bonds but also chemisorbed water molecules. For clarity purposes the analysis excluded data recorded for carbon C_{1s}, which was found in large amounts, up to 30 at.%, at binding energies corroborating adventitious carbon and carbonates findings. Importantly, the highest amount of the adsorbed carbonate species was found on Ti-Al-V sample surface, which is in very good agreement with SEM micrographs presented on **Fig. 11**. The least amount of carbonate species was once more found on the surface of Ti sample.

Table 8 – XPS deconvolution results carried out in Ti_{2p}, Cl_{2p} and O_{1s} energy range after 7 days of exposure to 0.9% NaCl solution at 37 °C (in at.%).

	Ti _{2p}	other	Me-O	O _{1s}		Cl _{2p}
	TiO ₂	additives		OH/CO	C=O/H ₂ O	Me-Cl
BE / eV	458.6	*	530.2	531.6	532.8	198.9
Ti	21.3	--	37.5	26.2	13.1	1.9
Ti-Al-V	17.4	4.3	28.8	25.7	20.8	3.0
Ti-Al-Nb	17.1	4.4	31.1	27.0	18.2	2.2
TC21	17.2	5.8	31.2	25.1	16.1	4.6

4. Conclusions

The effect of microstructure on the uniform and pitting corrosion characteristics of Ti-Al-V, and Ti-Al-Nb alloys is presented here. Pure Ti and TC21 alloy were included for comparison. Measurements were conducted in 0.9% NaCl solution at 37 °C employing various electrochemical techniques, and complemented with XRD and SEM/EDS examinations. The obtained results revealed that:

1. The microstructure of the investigated alloys consists of α matrix, which was strengthened by β phase in all studied alloys except cp-Ti alloy.
2. The volume fraction of β phase in TC21 alloy is higher than in both Ti-Al-V and Ti-Al-Nb alloys. In comparison with other alloys, Ti-Al-Nb alloy has the lowest volume fraction of β phase.
3. Ti-Al-Nb alloy has the highest corrosion resistance among other alloys where it has the lowest corrosion rate.
4. The addition of Nb alloying element at the expense of V in Ti-Al-V alloy decreased the volume fraction of β phase, which improves the corrosion resistance of Ti based alloy.
5. The XPS results revealed adsorption of chloride and carbonate species on the surface of the investigated alloys, which amount is the lowest for cp-Ti and Ti-Al-Nb alloys, affecting the observed corrosion resistance.
6. Corrosion studies revealed that the uniform and pitting corrosion rates increase following the sequence: Ti < Ti-Al-Nb < Ti-Al-V < TC21.

Supplementary Materials: The following are available online at www.mdpi.com/xxx/s1

Author Contributions: conceptualization, M.A. and R.B.; resources, N.E. and S.E.; investigation, S.I. and O.A. (XRD), A.F. and M.I. (uniform corrosion), M.A. and G.M. (passive layer breakdown), N.E., J.W. and S.E. (microstructure), J.R. (XPS), J.R. and J.W. (EIS); writing – original draft preparation, all authors; writing – review and editing, J.R., M.A. and R.B., project administration M.A.

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